



Office de la Propriété
Intellectuelle
du Canada

Un organisme
d'Industrie Canada

Canadian
Intellectual Property
Office

An agency of
Industry Canada

CA 2324794 A1 2002/04/25

(21) 2 324 794

(12) DEMANDE DE BREVET CANADIEN
CANADIAN PATENT APPLICATION

(13) A1

4/25/2002

(22) Date de dépôt/Filing Date: 2000/10/25

(41) Mise à la disp. pub./Open to Public Insp. 2002/04/25

(51) Cl.Int.⁷/Int.Cl.⁷ G03F 7/004, C08G 77/38, C08G 59/24

(71) Demandeur/Applicant:
AMERICAN DYE SOURCE, INC., CA

(72) Inventeurs/Inventors:
NGUYEN, MY T., CA;
NAZAROV, VADYM, CA

(74) Agent: GOUDREAU GAGE DUBUC

(54) Titre : COMPOSITIONS HYBRIDES ORGANIQUES/INORGANIQUES PHOTODURCISSABLES

(54) Title: ORGANIC-INORGANIC HYBRID PHOTOCURABLE COMPOSITIONS

(57) Abrégé/Abstract:

Described herein is a photocurable resin composition for stereolithography comprising (a) a photocurable component, liquid at room temperature and comprising a photopolymerizable substance selected from monomers, oligomers, dendrimers and polymers and mixtures thereof, (b) at least one photoinitiator compound, and (c) at least one photoactivated color changing compound. The color changing compound can be adapted to go from essentially colorless to a given color, one given color to another or from a given color to colorless. Optionally, the resin composition will also contain component (d), namely at least one reactive silsesquioxanes (POSS).

isopropyl thiioxanthone

1552-42-7

Canada

<http://opic.gc.ca> · Ottawa-Hull K1A 0C9 · <http://cipo.gc.ca>

OPIC · CIPO 191

ORGANIC-INORGANIC HYBRID PHOTOCURABLE COMPOSITIONS

FIELD OF THE INVENTION

This invention relates to colorless photocurable compositions, which produce
5 colored three-dimensional solid objects by stereolithographic processes. More
particularly, this invention relates to photocurable compositions comprising
(1) photocurable monomers, oligomers, dendrimers and polymers,
(2) photoinitiators, (3) color generating compounds and optionally, (4) soluble
reactive silsesquioxanes (POSS).

10

BACKGROUND OF THE INVENTION

U.S. patents 4,575,330 and 4,929,402 described a stereolithographic process, which can be employed to build up a predetermined three-dimensional object by forming series of layers of polymerized solids. The disclosure of U.S. patents
15 4,576,330 and 4,929,402 is incorporated herein by reference. During stereolithographic processing, a cross-section of the solid is traced out on the surface of a bath of liquid acrylate containing polymer precursors under the direction of a computer controlled system which causes the liquid to be exposed to a form of photoradiation such as ultraviolet or visible lasers. Exposure to
20 photoradiation causes the liquid to polymerize and harden. After each polymerized layer is formed and solidified, it is lowered in the bath so that a new solid layer can be formed on top. This technology has been found very useful in prototyping applications, since the prototypes can be rapidly and accurately built from computer-generated graphic models.

25

Photocurable compositions currently used for stereolithography are known in the art. Typical photocurable compositions for application in stereolithography may contain (1) photocurable monomers, oligomers and polymers, (2) photoinitiators and (3) optional insoluble organic or inorganic fillers, which are dispersed in the
30 composition. U.S. patents 5,510,226; 5,705,316 and 5,705,116 also teach to

prepare photocurable compositions containing monomers and oligomers, which have functional groups such as acrylate, methacrylate, epoxy and vinyl ether.

U.S. patents 5,629,133 and 5,639,413 teach photocurable compositions
5 comprising siloxane monomers, oligomers and polymers that contain epoxy functional groups.

U.S. patents 5,863,486 and 5,855,837 teach photocurable compositions containing inorganic fillers such as inorganic particles, whiskers, E-glass fibers, 10 woven glass fibers, and glass beads dispersed in the photocurable mixtures.

U.S. patent 6,036,910 teaches liquid photocurable resin composition for stereolithography, which comprises a photopolymerizable compound, a photopolymerization initiator and a colorant. The photocurable composition of 15 this prior art contains between 0.1 and 10 % by weight of photopolymerization initiator and 0.05 to 0.5% by weight of the colorant. The photopolymerizable compound is in an amount of the balance, based on the total weight of these components. The photocurable composition is liquid at normal temperature.

20 The inventors of this invention have also found that the presence of a colorant considerably reduced the shaping speed of the stereolithographic process due to the photoradiation absorption of the colorant. Moreover, the presence of colorant was also found to deteriorate drastically the mechanical and thermal properties of the resulting three-dimensional object.

25 Photocurable compositions disclosed in the above prior art do not provide desired colors for the resulting solid objects. They do not provide an image print-out during stereolithography so that the three-dimensional object may be seen as it is being made. They do not provide shelf-life and pot-life color 30 indicators. They also suffer by high degree shrinkage during photopolymerization resulting in considerable distortion in the shape of the final

objects. They are relatively unstable during operation due to the settlement of the filler particles. Furthermore, the stereolithographic objects obtained from the traditionally used photocurable compositions do not have a sufficiently high glass transition temperature (T_g) enough to withstand functional testing as engine parts or subsequent treatment processes such as drilling, machining and sanding.

Therefore, the object of this invention is to provide photocurable compositions for application in stereolithography to produce desirable colored, three-dimensional solid objects with fast stereolithographic shaping speed, non-settlement of insoluble filler particles, low degree of distortion and superior thermal stability and superior mechanical properties. Furthermore, the object of this invention is to provide photocurable compositions for application in stereolithography that produce color image print-outs during stereolithography and in-situ shelf-life indicators.

15

SUMMARY OF THE INVENTION

This invention relates to colorless liquid photocurable compositions for use in the production of desirable colored three-dimensional solid objects by stereolithography. In general terms, the present invention provides a photocurable resin composition for stereolithography comprising (a) a photocurable component, liquid at room temperature and comprising a photopolymerizable substance selected from monomers, oligomers, dendrimers and polymers and mixtures thereof, (b) at least one photoinitiator compound, and (c) at least one photoactivated color generating compound. The resin composition of the present invention may also comprise functionalized reactive silsesquioxanes (POSS).

DETAILED DESCRIPTION OF THE INVENTION

This invention relates to colorless liquid photocurable compositions to produce colored three-dimensional solid objects by stereolithography. More particularly, this invention relates to photocurable compositions comprising (a) a photocurable

monomers, oligomers, dendrimers and polymers, (b) photoinitiators, (c) color generating compounds and optionally, (d) non-settling functionalized reactive silsesquioxanes (POSS).

5 **Photocurable monomers, oligomers, dendrimers and polymers:**

The photocurable monomers, oligomers, dendrimers and polymers of this invention may contain functional groups, such as acrylate, epoxy, methacrylate, norbonyl, styryl and vinyl ether, which are essentially colorless liquids at room temperature. The amount of the photocurable monomers, oligomers, 10 dendrimers and polymers is between 60 and 95 %.

The preferred photocurable monomers, oligomers, dendrimers and polymers containing epoxy functional groups of this invention are the materials in which the epoxide groups form part of an alicyclic or heterocyclic ring system include 15 bis(2,3-epoxycyclopentyl) ether, 2,3-epoxycyclopentyl glycidyl ether, 1,2-bis(2,3-epoxycyclopentyloxy)ethane, bis(4-hydroxycyclohexyl)methane diglycidyl ether, 2,2-bis(4-hydroxycyclohexyl)propane diglycidyl ether, 3,4-epoxycyclohexylmethyl 3,4-epoxycyclohexanecarboxylate, 3,4-epoxy-6-methyl-cyclohexylmethyl 3,4-epoxy-6-methylcyclohexanecarboxylate, di(3,4-epoxycyclohexylmethyl) 20 hexanedioate, di(3,4-epoxy-6-methylcyclohexylmethyl) hexanedioate, ethylenebis(3,4-epoxycyclohexane-carboxylate), ethanediol di(3,4-epoxycyclohexylmethyl) ether, vinylcyclohexene dioxide, dicyclopentadiene diepoxide or 2-(3,4-epoxycyclohexyl-5,5-spiro-3,4-epoxy)cyclohexane-1,3-dioxane.

25 Preferred compositions are those in which the free radically curable component contains a tri(meth)acrylate or a penta(meth)acrylate. Suitable examples of di(meth)acrylates are the di(meth)acrylates of cycloaliphatic or aromatic diols such as 1,4-dihydroxymethylcyclohexane, 2,2-bis(4-hydroxy-30 cyclohexyl)propane, bis(4-hydroxycyclohexyl)methane, hydroquinone, 4,4'-dihydroxybi-phenyl, Bisphenol A, Bisphenol F, bisphenol S, ethoxylated or

propoxylated Bisphenol A, ethoxylated or propoxylated Bisphenol F or ethoxylated or propoxylated Bisphenol S. Di(meth)acrylates of this kind are known and some are commercially available.

5 **Photoinitiator System:**

A photoinitiator system according to this invention may comprise both radical and acid photoinitiators. The radical photoinitiators are employed for polymerization of materials containing acrylate, methacrylate, norbonyl and styryl functional groups. The acid photoinitiators are used for polymerization of 10 materials containing epoxy, hydroxy and vinyl ether.

Radical photoinitiators are known in the art. Such compounds are benzoin, benzoin ethers, benzoin acetate, acetophenones, benzil, benzil ketals, anthraquinones, triphenylphosphine, benzophenones, and 1-hydroxyphenyl 15 ketones. The preferred radical photoinitiators according to this invention are 2,2-dialkoxybenzophenones, 1-hydroxyphenylketones, benzil ketal and benzoylphosphine oxide, for example 1-hydroxycyclohexylphenyl ketone, 2-hydroxy-2,2-dimethylacetophenone, benzil dimethylketal and 2,4,6-trimethylbenzoylphosphine oxide.

20 Acid photoinitiators are also known in the art as described in EP-A 153 904 which include onium salts with anions having weak nucleophilicity such as SbF_6 , BF_4 , PF_6 , sulfoxonium salts, for example as described in EP-A 35 969, 54 509 and 164 314, or diazonium salts, for example as described in U.S. Patent 3,708,296. 25 Other acid photoinitiators are metallocene salts, for example as described in EP-A 94 914 and 94 915.

Photoinitiators are added in effective amounts, for example in amounts of from 30 approximately 0.1 to approximately 10% by weight each, based on the total amount of the mixture. When the mixtures according to the invention are used for stereolithographic processes, in which laser beams are commonly used, it is

essential that the absorption capacity of the mixtures is so matched in terms of the type and the concentration of the photoinitiator that the curing depth at normal laser speed is approximately from 0.1 to 2.5 mm. The total amount of photoinitiators in the compositions according to the invention is preferably from

5 0.5 to 5% by weight.

Color Generating Compounds:

The photocurable composition of this invention may comprise color generating compounds, which are preferably colorless and soluble in the photocurable mixture.

10 Optionally, the color generating compound may be of a first given color which discernibly changes upon photoactivation. Also, the color generating compound could be of a given color which changes to essentially colorless upon 15 photoactivation. All these possibilities provide the benefit of a color change resulting from photoactivation. This color change allows to see the object being created during stereolithography since the stereolithographic object has a different color when compared to the initial liquid composition. Further, the photoactivated compound acts as a shelf life and pot life indicator. When the 20 liquid composition of the present invention is degenerated by light pollution, the color change will occur. For the purpose of the present disclosure, the expression shelf life is meant to include the pot life of the liquid composition once placed in the stereolithography bath.

25 Preferably, the color generating compounds are the derivatives of triarylpyridine, xanthene and isobenzofuranone. The most preferable color generating compounds of this present invention are the compounds that are colorless and which develop colors in the presence of free radical or acid. These compounds are:

3',6'-bis[N-[2-chlorophenyl]-N-methylamino]spiro[2-butyl-1,1-dioxo[1,2-benzoisothiazole-3(3H),9'-(9H)xanthene]] (prepared by the method of U.S. Pat. No. 4,345,017).

5 3',6'-bis[N-[2-[methanesulfonyl]phenyl]-N-methylamino]spiro[2-butyl-1,1-dioxo[1,2-benzoisothiazole-3(3H),9'-(9H)xanthene]](prepared by the method of U.S. Pat. No. 4,345,017).

9-Diethylamino[spiro[12H-benzo(a)xanthene-12,1'(3'H)-isobenzofuran]-3'-one]
10 (available from Hilton Davis Co., Cincinnati, Ohio).

2'-di(phenylmethyl)amino-6'-[diethylamino]spiro[isobenzofuran-1(3H),9'-(9H)-xanthen]-3-one (available from Hilton Davis Co., Cincinnati, Ohio).

15 3-[butyl-2-methylindol-3-yl]-3-[1-octyl-2-methylindol-3-yl]-1-(3H)-isobenzofuranone (available from Hilton Davis Co., Cincinnati, Ohio).

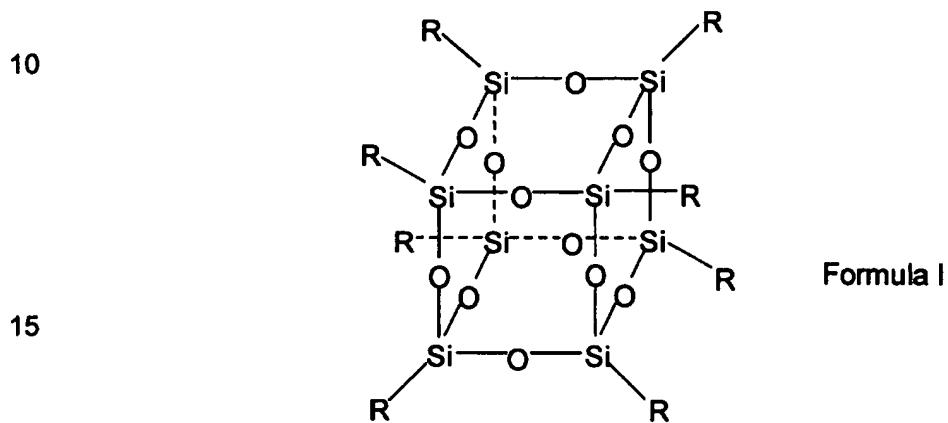
6-[dimethylamino]-3,3-bis[4-dimethylamino]-phenyl-(3H)-isobenzofuranone 1552-42-7
(available from Hilton Davis Co., Cincinnati, Ohio).

20 2-[2-Octyloxyphenyl]-4-[4-dimethylaminophenyl]-6-phenylpyridine (available from Hilton Davis Co., Cincinnati, Ohio).

Photocurable and non-settling silsesquioxane (POSS):

25 Surprisingly, it has been found in the course of the present invention that these compounds can be functionalized so as to become photocurable and to become soluble or at least dispersible in the resin composition of the present invention. Silsesquioxanes can provide advantageous mechanical properties such as hardness and modulus to the finished stereolithographic object.

The photocurable compositions described this invention may thus comprise polyhedral oligomeric silsesquioxanes (POSS) having a chemical structure according to Formula I, below, where R can be alkyl, cycloalkyl, alkoxy, aryl, polyether, dimethylsiloxane and polyether. These substituent are preferred to 5 contain reactive functional groups, such as acrylate, alcohol, epoxy, methacrylate, styryl and vinyl ether, which can undergo polymerization in the presence of free radical or acid.



The functionalized silsesquioxanes according to this invention are non-settling in 20 the photocurable composition. This means that the functionalized silsesquioxanes may be soluble or dispersible in the photocurable compositions.

The syntheses of the functionalized silsesquioxanes of this invention are commercially available or they were synthesized according to the procedure 25 published by C. Bönn et. al., Chem. Mat. Vol. 9, No. 6, 1997, pages 1475 – 1479. A review about silsesquioxanes can be found in Chem. Rev. 1995, 95, 1409 – 1430.

The preferred soluble reactive silsesquioxane of this invention are:

3-(3,5,7,9,11,13,15-Heptacyclopentylpentacyclo[9.5.1.1^{3,9}.1^{5,15}.1.7¹³]octasiloxan-1-yl)propyl methacrylate (available from Aldrich Chemical, Oakville, Ontario).

5

3-(3,5,7,9,11,13,15-Heptacyclopentylpentacyclo[9.5.1.1^{3,9}.1^{5,15}.1.7^{,13}]octasiloxan-1-yl)propyl epoxy (available from Hybrid Plastics, Fountain Valley, California).

1-[2-(5-Norbornen-2-yl)ethyl]-3-(3,5,7,9,11,13,15-heptacyclopentylpentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from Aldrich Chemical, Oakville, Ontario).

1,3,5,7,9,11,13-octakis(2(2-(2-hydroxy)ethoxy)ethoxy)pentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from American Dye Source, Inc.,
15 Mount Royal, Quebec).

1,3,5,7,9,11,13-octakis(2(2-hydroxy)ethoxy)pentacyclo- [9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]-octasiloxane (available from American Dye Source, Inc., Mount Royal, Quebec).

20 1,3,5,7,9,11,13-octakis(2-hydrobutyldimethylsilylpentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from Hybrid Plastics, Fountain Valley, California).

1,3,5,7,9,11,13-octakis(hydroxypropyl-1,2-butoxylate-block-ethoxylate)-
25 pentacyclo[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from American Dye
Source, Inc., Mount Royal, Quebec).

1,3,5,7,9,11,13-octakis(3-hydroxypropylidemethylsilyloxy)pentacyclo
[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from American Dye Source, Inc.,
30 Mount Royal, Quebec).

1-(2-hydroxyethoxylate-block-1,2-butoxylatepropyl)3,5,7,9,11,13-heptacyclopentylpentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane (available from American Dye Source, Inc., Mount Royal, Quebec).

5 PREPARATION OF PHOTOCURABLE COMPOSITONS:

The colorless liquid photocurable compositions of this present invention were prepared by mixing all the ingredients at room temperature in a mixing apparatus, which is equipped with stainless steel vat and a mechanical stirrer. After all the components have been dissolved, the photocurable composition 10 was filtered through 1.0 μm absolute filter to remove any solid residue. The three-dimensional solid object parts were built using SLA 3500 stereolithography machine from 3D Systems (Valencia, California).

Ingredients	Example 1 (Weight %)	Example 2 (Weight %)	Example 3 (Weight %)	Example 4 (Weight %)
Celloxide 2021P	24.23	24.23	24.23	24.23
Celloxide 2081	21.23	22.23	22.23	24.23
POSS2020	2.00	2.00	2.00	2.00
SR351	12.25	12.25	12.25	12.25
Epotech YD128	12.25	12.25	12.25	12.25
Placcel 303	19.42	19.42	19.42	19.42
Cyrcure UVI6974	5.6	5.6	5.6	5.6
Irgacure 184	2	2	2	2
ITX	0.0125	0.0125	0.0125	0.0125
Copikem 35		0.0125		
Copikem 1 Blue, CVL			0.0125	
Copikem 37				0.0125

15 Celloxide 2021P is alicyclic diepoxide, which is available from Daicel USA Inc. (Fort Lee, New Jersey, USA).

Celloxide 2081 is polycaprolactone diepoxy, which is available from Daicel USA Inc. (Fort Lee, New Jersey, USA).

POSS2020 is 1,3,5,7,9,11,13-octakis(hydroxypropyl-1,2-butoxylate-block-5 ethoxylate)-pentacyclo[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane, which is available from American Dye Source, Inc.,(Mount Royal, Quebec, Canada).

SR351 is trimethylolpropane triacrylate, which is available from Satomers Company Inc. (Exton, Pennsylvania, USA).

10 Epotech YD128 is bisphenol A diglycidyl ether, which is available from Van Waters & Rogers Ltd. (Montreal, Quebec, Canada).

15 Placcel 303 is polycaprolactonetriol, which is available from Daicel USA Inc. (Fort Lee, New Jersey, USA).

Cyacure UVI6974 is a mixture of triaryl sulfonium hexafluoroantimonate salts, which is available from Union Carbide (Danbury, Connecticut, USA).

20 Irgacure 184 is 1-hydroxy-cyclohexyl phenyl ketone, which is available from Ciba Specialty Chemicals (Mississauga, Ontario, Canada).

ITX is a mixture of 2-isopropylthioxanthone and 4-isopropylthioxanthone, which is available from Lambson (Castleford, West Yorkshire, United Kingdom).

25 Copikem 35 is 3-[butyl-2-methylindol-3-yl]-3-[1-octyl-2-methylindol-3-yl]-1-(3H)-isobenzofuranone, which is available from Hilton Davis Co. (Cincinnati, Ohio, USA).

Copikem 37 is 2-[2-octyloxyphenyl]-4-[4-dimethylaminophenyl]-6-phenylpyridine, which is available from Hilton Davis Co., Cincinnati, Ohio, USA.

5 Copikem 1 Blue, CVL is 6-(dimethylamino)-3,3-bis(4-dimethylamino)phenyl-(3H)-isobenzofuranone, which is available from Hilton Davis Co., Cincinnati, Ohio, USA.

Parameters	Method	Example 1	Example 2	Example 3	Example 4
Viscosity at 30 °C (cPs)	Brookfield	280	278	280	278
Critical exposure (mJ/cm ²)	Window-panes	8	8	8	8
Penetration depth (mils)	Window-panes	6.1	6.1	6.1	6.1
Color of solid object	Visual	Colorless	Magenta	Cyan	Yellow
Tensile strength (MPa)	ASTM D 638M	23.15	22.64	23.10	23.80
Tensile modulus (MPa)	ASTM D 638M	1 593	1480	1600	1520
Elongation @ break (%)	ASTM D 638M	89.8	87.1	91.8	90.2
Flexural strength (MPa)	ASTM D 790M	32.8	31.4	30.4	30.9
Flexural modulus (MPa)	ASTM D 790M	699.63	701.85	698.43	700.3
Impact strength (J/m)	ASTM D 256M	40	39	38	40

Parameters	Method	Example 1	Example 2	Example 3	Example 4
Hardness (Shore D)	ASTM D 2240	85	83	83	85

These tests clearly show that the inventive composition and its method of preparation provide photocurable resin compositions having improved mechanical properties over the prior art and having tailor made colors.

I claim:

1. A photocurable resin composition for stereolithography comprising (a) a photocurable component, liquid at room temperature and comprising a photopolymerizable substance selected from monomers, oligomers, dendrimers and polymers and mixtures thereof, (b) at least one photoinitiator compound, and (c) at least one photoactivated color changing compound.
- 10 2. The resin composition of claim 1 wherein said composition is a solution of components (a) (b) and (c) and is essentially colorless.
- 15 3. The resin composition of claim 1 wherein said photopolymerizable substance is essentially colorless and each of said monomers, oligomers, dendrimers and polymers contains photoactivated functional groups selected from the group of functional groups consisting of: acrylate, epoxy, methacrylate, norbonyl, styryl and vinyl ether.
- 20 4. The resin composition of claim 3 wherein said photopolymerizable substance is present in a proportion of about 60 to about 95% by weight based on the weight of the resin composition.
- 25 5. The resin composition of claim 4 wherein said photoactivated functional group comprises an epoxy group.
6. The resin composition of claim 5 wherein said photopolymerizable substance is:
bis(2,3-epoxycyclopentyl) ether,
2,3-epoxycyclopentyl glycidyl ether,
30 1,2-bis(2,3-epoxycyclopentyloxy)ethane,
bis(4-hydroxycyclohexyl)methane diglycidyl ether,

2,2-bis(4-hydroxycyclohexyl)propane diglycidyl ether,
3,4-epoxycyclohexyl-methyl-3,4-epoxycyclohexanecarboxylate,
3,4-epoxy-6-methyl-cyclohexylmethyl-3,4-epoxy-6-methylcyclohexane-
carboxylate,
5 di(3,4-epoxycyclohexylmethyl)hexanedioate,
di(3,4-epoxy-6-methylcyclohexylmethyl)hexanedioate,
ethylenebis(3,4-epoxycyclohexane-carboxylate,
ethanediol di(3,4-epoxycyclohexylmethyl) ether,
vinylcyclohexene dioxide,
10 dicyclopentadiene diepoxide, or
2-(3,4-epoxycyclohexyl-5,5-spiro-3,4-epoxy)cyclohexane-1,3-dioxane.

7. The resin composition of claim 4 wherein said photoactivated functional group comprises a tri(meth)acrylate group.

15 8. The resin composition of claim 7 wherein said photopolymerizable substance is:
1,4-dihydroxymethylcyclohexane, 2,2-bis(4-hydroxy-cyclohexyl)propane,
bis(4-hydroxycyclohexyl)methane, hydroquinone, 4,4'-dihydroxybi-
20 phenyl, Bisphenol A, Bisphenol F, Bisphenol S, ethoxylated or propoxylated Bisphenol A, ethoxylated or propoxylated Bisphenol F or ethoxylated or propoxylated Bisphenol S.

9. The resin composition of claim 4 wherein said photoactivated functional group comprises a penta(meth)acrylate group.

25 10. The resin composition of claim 3 wherein said photoactivated functional groups are selected from the group of functional groups consisting of:
acrylate, methacrylate, norbonyl, and styryl and wherein said photoinitiator is a radical photoinitiator.

30

11. The resin composition of claim 10 wherein said radical photoinitiator is selected from the group of photoinitiators consisting of benzoin, benzoin ethers, benzoin acetate, acetophenones, benzil, benzil ketals, anthraquinones, triphenylphosphine, benzophenones, and 1-hydroxyphenyl ketones.
5
12. The resin composition of claim 11 wherein said photoinitiator is: 2,2-dialkoxybenzophenones, 1-hydroxyphenylketones, benzil ketal and benzoylphosphine oxide, for example 1-hydroxycyclohexylphenyl 10 ketone, 2-hydroxy-2,2-dimethylacetophenone, benzil dimethylketal or 2,4,6-trimethylbenzoylphosphine oxide.
13. The resin composition of claim 12 wherein said photoactivated functional groups are selected from the group of functional groups consisting of: 15 epoxy, hydroxy and vinyl ether and wherein said photoinitiator is an acid photoinitiator.
14. The resin composition of claim 13 wherein said acid photoinitiators are selected from the group of photoinitiators consisting of: 20 onium salts with anions having weak nucleophilicity, sulfoxonium salts, diazonium salts, and metallocene salts.
15. The resin composition of claim 1 wherein said photoinitiators are present in proportions of about 0.1 to about 10% by weight based on the weight 25 of the resin composition.
16. The resin composition of claim 15 wherein said photoinitiators are present in proportions of about 0.5 to about 5% by weight based on the weight of the resin composition.

17. The resin composition of claim 1 wherein the photocurable resin composition has a photoradiation absorption level so that under response from a given photoradiation source it will become polymerized and consequently solidified to a curing depth of about 0.1 to about 2.5 mm.
5
18. The resin composition of claim 1 wherein the at least one photoactivated color generating compound is essentially colorless and soluble in the photocurable resin composition.
- 10 19. The resin composition of claim 1 wherein the at least one photoactivated color generating compound is of a first color prior to photoactivation and of a second color, discernible by visual inspection from the first color, after photoactivation.
- 15 20. The resin composition of claim 1 wherein the at least one photoactivated color generating compound is of a first color prior to photoactivation and essentially colorless after photoactivation.
21. The resin composition of claim 18 wherein the photoactivated color generating compound is a shelf life indicator for the resin composition.
20
22. The resin composition of claim 19 wherein the photoactivated color generating compound is a shelf life indicator for the resin composition.
- 25 23. The resin composition of claim 20 wherein the photoactivated color generating compound is a shelf life indicator for the resin composition.
24. The resin composition of claim 1 wherein the photoactivated color generating compound is selected from the group of compounds consisting
30 of:

derivatives of triarylpyridine, xanthene, isobenzofuranone and mixtures thereof.

5 25. The resin composition of claim 24 wherein the photoactivated color generating compound is:

3',6'-bis[N-[2-chlorophenyl]-N-methylamino]spiro[2-butyl-1,1-dioxo[1,2-benzisothiazole-3(3H),9'-(9H)xanthene]],

3',6'-bis[N-[2-[methanesulfonyl]phenyl]-N-methylamino]spiro[2-butyl-1,1-dioxo[1,2-benzisothiazole-3(3H),9'-(9H)xanthene]],

10 9-Diethylamino[spiro[12H-benzo(a)xanthene-12,1'(3'H)-isobenzofuran)-3'-one],

2'-di(phenylmethyl)amino-6'-[diethylamino]spiro[isobenzofuran-1(3H),9'-(9H)-xanthen]-3-one,

15 3-[butyl-2-methylindol-3-yl]-3-[1-octyl-2-methylindol-3-yl]-1-(3H)-isobenzo-furanone

6-[dimethylamino]-3,3-bis[4-dimethylamino]-phenyl-(3H)-isobenzofuranone or

2-[2-octyloxyphenyl]-4-[4-dimethylaminophenyl]-6-phenylpyridine.

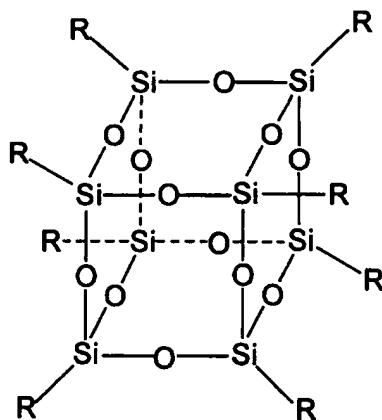
20 26. The resin composition of claim 1 further comprising at least one reactive silsesquioxanes (POSS).

27. The resin composition of claim 26 wherein said at least one reactive silsesquioxanes (POSS) is non-settling in said photocurable resin composition.

25

28. The resin composition of claim 27 wherein said at least one reactive silsesquioxanes (POSS) is represented by formula I below:

5



10

15

Formula I:

Where R is alkyl, cycloalkyl, alkoxy, aryl, polyether, dimethylsiloxane or polyether.

29. The resin composition of claim 28 wherein R contains reactive functional groups selected from the group of functional groups consisting of: acrylate, alcohol, epoxy, methacrylate, styryl and vinyl ether, said reactive functional group capable of undergoing cross-polymerization in the presence of radical or acid initiators.

25 30. The resin composition of claim 29 wherein said functionalized silsesquioxanes are:

3-(3,5,7,9,11,13,15-heptacyclopentylpentacyclo[9.5.1.1^{3,9}.1^{5,15}.1.7,13]octasiloxan-1-yl)propyl methacrylate,

3-(3,5,7,9,11,13,15-Heptacyclopentylpentacyclo[9.5.1.1^{3,9}.1^{5,15}.1.7,13]octasiloxan-1-yl)propyl epoxy,

30

1-[2-(5-Norbornen-2-yl)ethyl]-3-(3,5,7,9,11,13,15-heptacyclopentyl
pentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane,
1,3,5,7,9,11,13-octakis(2(2-hydroxyethoxyethoxy)pentacyclo-
[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane,
5 1,3,5,7,9,11,13-octakis(2(2-hydroxyethoxy)pentacyclo-
[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane,
1,3,5,7,9,11,13-octakis(2-hydrobutyldimethylsilylpentacyclo-
[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane,
1,3,5,7,9,11,13-octakis(hydroxypropyl-1,2-butoxylate-block-ethoxylate)-
10 pentacyclo[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane,
1,3,5,7,9,11,13-octakis(3-hydroxypropylidemethylsilyloxy)pentacyclo
[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane or
1-(2-hydroxyethoxylate-block-1,2-butoxylatepropyl)3,5,7,9,11,13-
heptacyclopentylpentacyclo-[9.5.1.1^{3,9}.1^{5,15}.1^{7,13}]octasiloxane.

15

31. A method of preparing the photocurable resin composition of claim 1, said method comprising the steps of:
mixing components (a), (b) and (c) at room temperature in a mixing apparatus;
20 and filtering the resulting photocurable resin composition to remove solid particles having a diameter exceeding a predetermined value.

32. The method of claim 31 wherein said predetermined value is 1 μ m.